



MBW50T120PHF

1200V Field stop IGBT Data sheet

General Descriptions

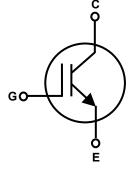
This IGBT is produced using advanced Magnachip's Field Stop Trench IGBT Technology, which provides low $V_{\text{CE}(\text{SAT})}$, high switching performance and excellent quality.

Features

- 1200V Trench + Field stop technology
- Low switching losses
- Positive temperature coefficient
- High Input Impedance

Applications

■ Low / medium power drives



Chip Type	V _{CE} Ic(Note 1, 2)		Package	
MBW50T120PHF	1200V	50A	Sawn on foil	

Mechanical Parameters

Parameter	Condition/ Material	Value	Unit		
Die size	LxW	7.333 x 6.923	mm²		
Scribe lane	Width	0.1	mm²		
Emitter pad size	-	See chip drawing	mm²		
Gate pad size	LxW	1.578 x 0.84	mm²		
Thickness		128±5	um		
Wafer size		190	mm		
Net die		477	EA		
Pad metal	AlSiCu	4000	nm		
Backside metal	Al/Ti/Ni/Ag	1600	nm		
Passivation frontside		Polyimide			
Die bond		Conductive epoxy glue and soft solder			
Wire bond		Al< 500um			
Reject die identification		Mapping or Inking			
Storage environment		Sawn on foil product is intended for immediate use and hat a limited shelf life, this is based on standard condition temperature atmosphere below 25 °C			

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Absolute Maximum Ratings

Parameter	Symbol	Rating	Unit
Collector-emitter voltage T _{vj} =25 °C	Vce	1200	V
Gate-emitter voltage	V_{GE}	±20	V
DC collector current, limited by T _{vj max}	Ic	(Note 2)	Α
Pulsed collector current, t _p limited by T _{vj max} (Note 3)	IC, Pulse	150	Α
Short circuit time $V_{CC} \le 600V$, $V_{GE} = 15V$, $T_{vj} = 150^{\circ}C$ (Note 3)	t _{sc}	10	μs
Operating Junction temperature	T _{vj}	-40~175	°C

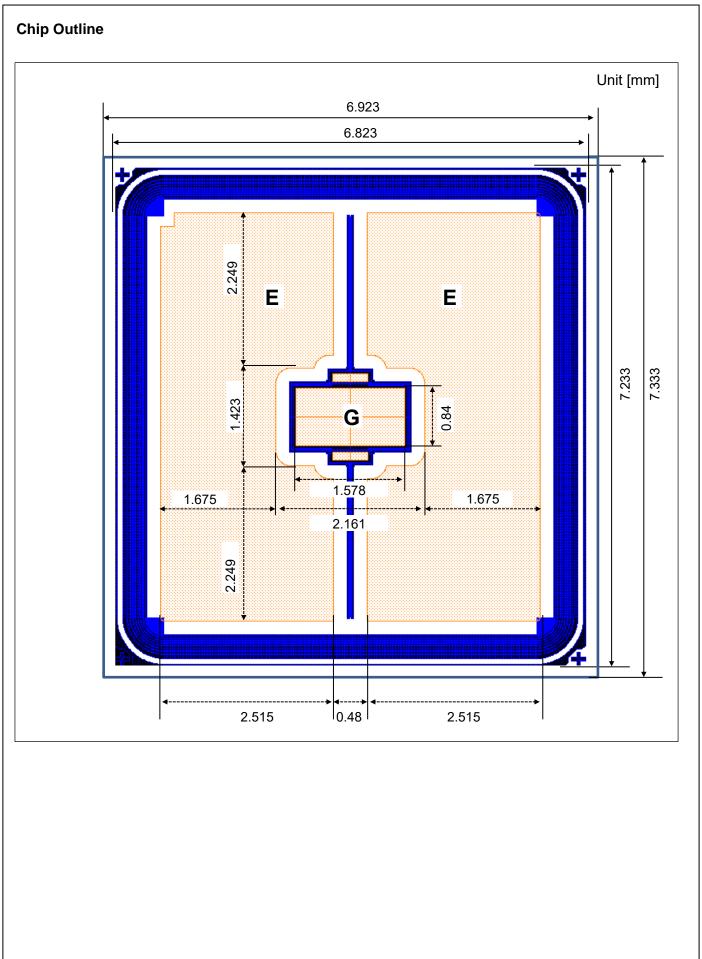
Note 1: nominal collector current at $T_C=100\,^{\circ}C$, not subject to production test-verified by design/characterization Note 2: depending on thermal properties of assembly Note 3: not subject to production test - verified by design/characterization

Static Characteristics (T_{vj} =25°C unless otherwise specified and Tested on wafer)

Parameter	Symbol	Test Condition	Min.	Тур.	Max.	Unit.
Collector-emitter breakdown voltage	BVces	I _C = 5mA, V _{GE} = 0V	1200	-	-	V
Gate-emitter threshold voltage	V _{GE(th)}	Ic = 1mA, VcE = VgE	4.8	-	6.8	V
Zero gate voltage collector current	Ices	V _{CE} = 1200V, V _{GE} = 0V	-	-	10	uA
Gate-emitter leakage current, Forward	I _{GES(F)}	V _{GE} = 20V, V _{CE} = 0V	-	-	120	nA
Gate-emitter leakage current, Reverse	I _{GES(R)}	V _{GE} = -20V, V _{CE} = 0V	-	-	120	nA
Collector-emitter saturation voltage	V _{CE(sat)}	V _{GE} = 15V, I _C = 50A	1.50	1.85	2.20	V
Integrated gate resistor	r _G			4.0		Ω

Electrical Characteristics (not subject to production test – verified by design / characterization)

Parameter	Symbol	Test Condition	Min.	Тур.	Max.	Unit.
Collector-emitter saturation voltage	V _{CE(sat)}	I _C = 50A, V _{GE} = 15V, T _{vj} = 175°C		2.20		V
Input capacity	Cies	4 4MIL T 25°C V 25V		3000		pF
Reverse transfer capacitance	Cres	$f = 1MHz, T_{vj} = 25^{\circ}C, V_{CE} = 25V$		140		pF



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